



Form PTO 1449

(Rev. 2-32)

U.S. Department of Commerce
Patent and Trademark OfficeAtty. Docket No.
LMPY-11610Serial No.:
09/858,147

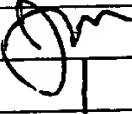
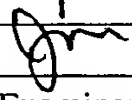
Information Disclosure Statement by Applicant

Applicant:
Rustem Osmanow, et al.

(Use several sheets if necessary)

Filed: May 14, 2001 Group: 2881

U.S. Patent Documents

Init.	Document No.	Date	Name	Class	Subclass	Filing Date
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Examiner

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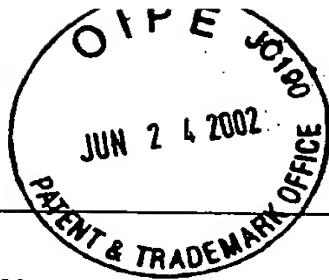
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Examiner				Date Considered 8/23/02		

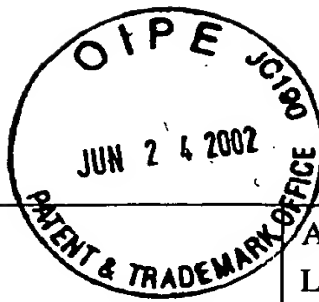
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Translation								
Init.		Document No.	Date	Country	Class	Subclass	Yes	No
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